

W thick coatings on CuCrZr and steel for plasma facing components

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INTRODUCTION

Thick tungsten coatings represents a viable solution for the manufacture of the plasma facing first wall material in future devices. The heat loads, much smaller than for divertor components, they are foreseen to withstand and their capability in limiting erosion by sputtering guarantee a long time life to this first wall solution.

Among the techniques able to deposit thick W coatings, plasma spray is probably the simplest and the most attractive from the economical point of view.

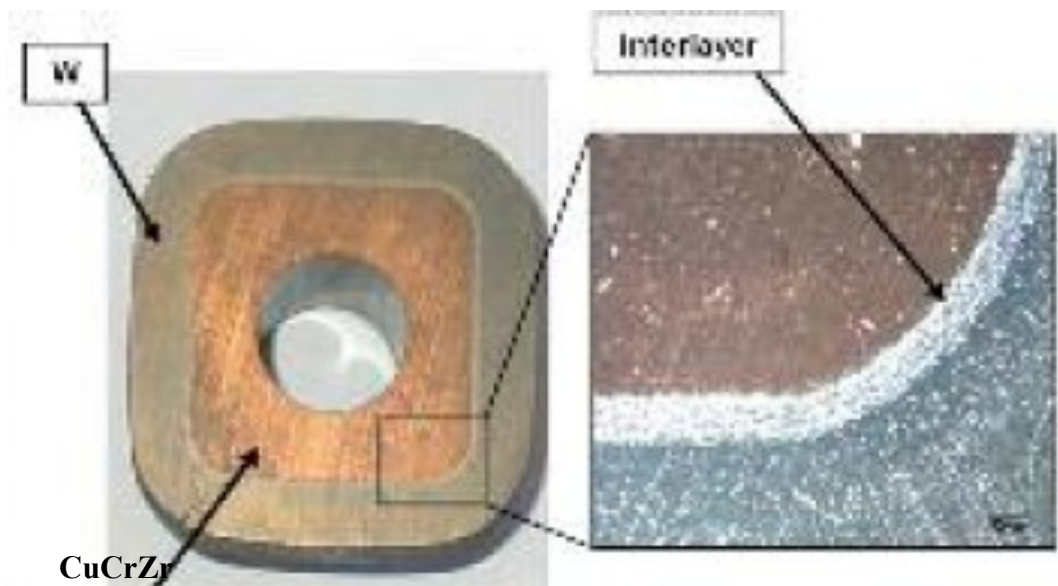
For the successfull outcome of the coating, an appropriate interlayer must be ideposited on the substrate to limit the mismatch between substrate and W.

In this work some investigations on the effectiveness of the following coating/interlayer/substrate combinations are reported and discussed:

Plasma facing coating	Interlayer	Substrate
W	NiAl, SiAl and W	CuCrZr
W	NiAl, SiAl and W	AISI 316
W	SiAl and W	AISI 316

MATERIAL

W on CuCrZr ; Interlayer: W + Ni-20%Al + Al-12%Si



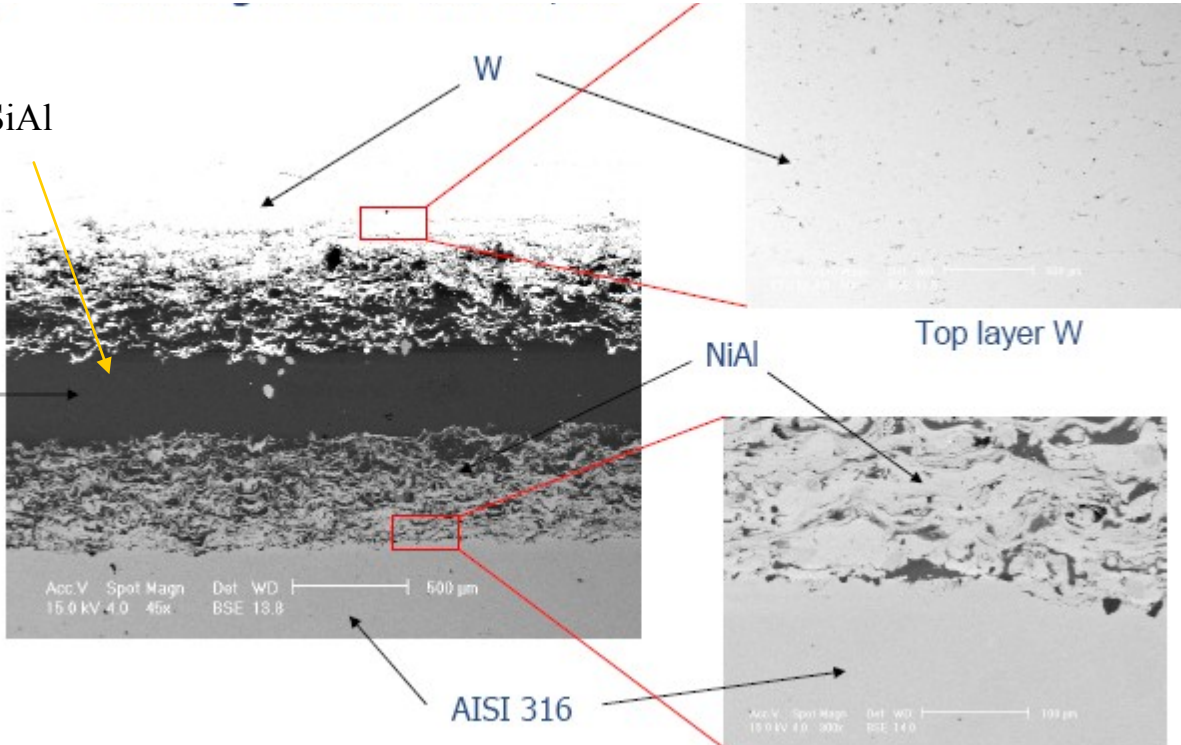
This coating/interlayer/ substrate combination has been successfully tested under thermal fatigue tests performed at the electron beam facility FE200 (Le Creusot-France). The mock up with 5 mm thick W coating realised with the **low pressure plasma spray** technique withstood heat fluxes up to 5 MWm⁻² in cooling conditions relevant for ITER.

B.Riccardi et al., 17th IEEE/NPSS Symposium on Fusion Engineering, (1997) vol 2 pag. 910

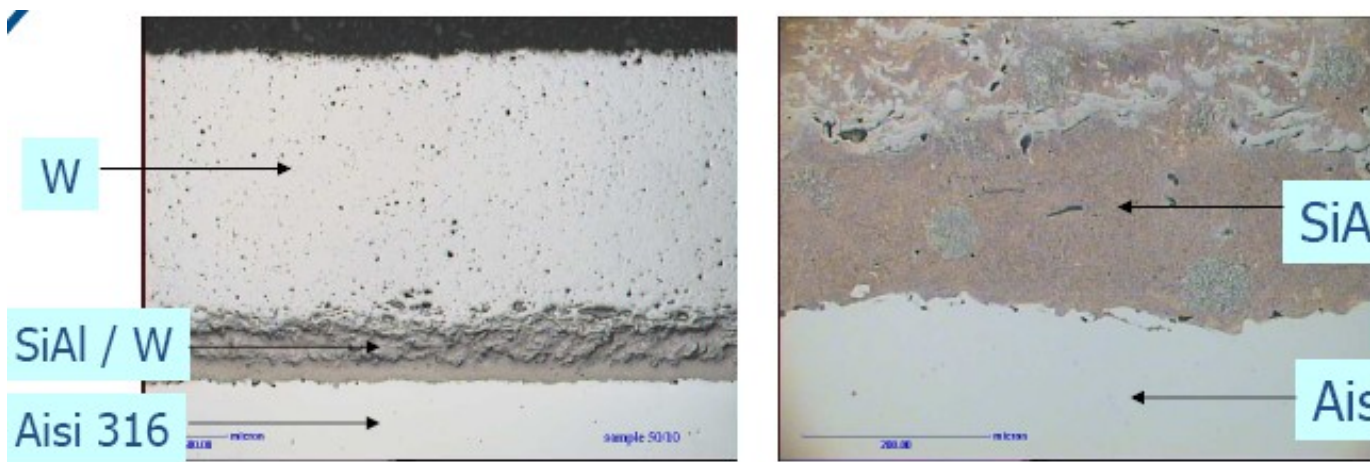
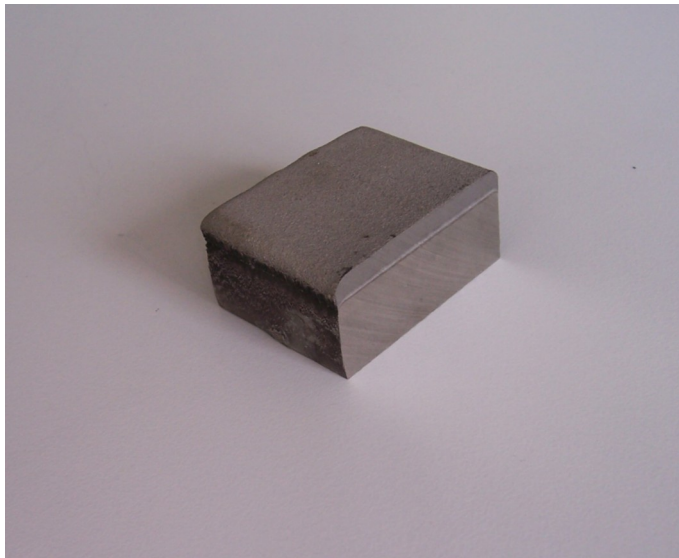
W on AISI 316 ; Interlayer:W + Ni-20%Al + Al-12%Si



High Pressure Plasma Spray

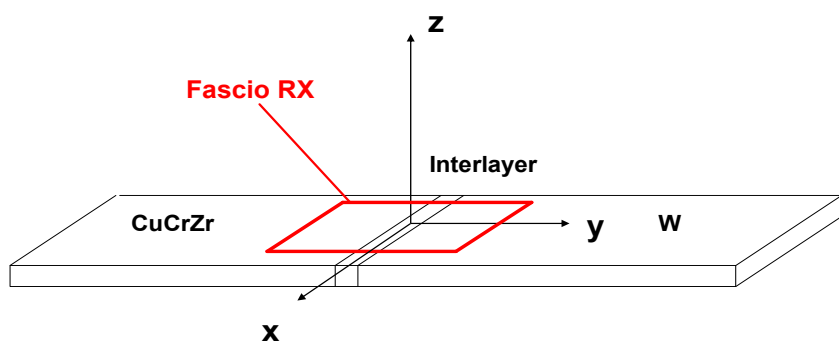


W on AISI 316 ; Interlayer: W + Al/12%Si



ANALYTICAL TECHNIQUES

- Density measurements
- Optical and electron microscopy
- X-ray difratometry (up to 400 °C in argon atmosphere)
- EDS mapping, XPS, AES
- Inductively coupled plasma emission spectroscopy (ICP-ES)
- Flat top cylindrical indentation (FIMEC)



RESULTS

W on CuCrZr

